## **Electronic Supplementary Information (ESI)**

# Copper(I) and cobalt(II) frameworks with a tetraphenyletheneimidazole ligand for electroreduction CO<sub>2</sub> to CH<sub>4</sub>

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#### **Physical measurements**

Powder X-ray diffraction patterns (PXRD) of the samples were measured on the Bruker D8 Advance X-ray diffractometer using Cu-K $\alpha$  ( $\lambda = 1.5418$  Å) radiation. The voltage of the instrument was 40 kV, the current was 40 mA. The total reflection infrared (ATR-IR) spectra of the samples were obtained using a Fourier transform infrared (FTIR) spectrometer (TENSOR 27) with a spectral range of 4000 - 400 cm<sup>-1</sup>. Thermalgravimetric analysis (TGA) was conducted on the Mettler-Toledo (TGA/DSC1) thermal analyzer, and TGA was performed under N<sub>2</sub> at a heating rate of 10 °C min<sup>-1</sup>. The elemental content of the samples was determined by the Elementar UNICUBE element analyzer. X-ray photoelectron spectroscopy (XPS) was performed on ThermoFisher Nexsa with aluminum Al radiation.

#### Working electrode preparation

A homogenous ink was formed by sonicating 950 µL of isopropanol solution with 10 mg of

catalyst and 50  $\mu$ L of Nafion solution (5 wt%) for 0.5 h. Subsequently, 200  $\mu$ L of the uniform ink dispersion was transferred onto a 1 x 1 cm<sup>2</sup> carbon paper (CP) electrode and allowed to dry in the ambient environment.

#### **Electrochemical test**

Electrocatalytic CO<sub>2</sub>RR tests were performed using a three-channel flow cell on the electrochemical workstation (CHI 730E, Chenhua, Shanghai). Electrochemical impedance spectroscopy (EIS) was performed on the Zahner electrochemical workstation (IM6ex, Zahner Scientific Instruments, German). Cyclic voltammetry (CV) profiles and linear sweep voltammetry (LSV) curves were measured at a sweep rate of 100 mV s<sup>-1</sup> with N<sub>2</sub>/CO<sub>2</sub>. All potentials in this work were converted to reversible hydrogen electrodes (RHE) using the Nernst equation:  $E_{RHE} = E_{Hg/HgO} + 0.098 + 0.059 \times pH$ .

#### **Product quantification**

An online gas chromatograph was used for the separation and identification of the components of a gas mixture. The potential products (H<sub>2</sub>, CH<sub>4</sub>, CO, C<sub>2</sub>H<sub>4</sub>) emerging from the outlet of the cathodic compartment were directly vented into the gas chromatograph system (GC9790II, Fuli), which was equipped with a thermal conductivity detector (TCD) and flame ionization detector (FID) with a methaniser. The gas chromatograph was equipped with a Molecular Sieve 5A column, a Popapak N column, and a Haysep4 column. Argon (Tianhong Gas, 99.999%) was used as the carrier gas, with a GC run initiated every 18 min. High-purity Ar (99.999%) was used as the carrier gas.

<sup>1</sup>H NMR spectra were collected on a Bruker DRX 500 MHz spectrometer. The NMR samples were prepared by mixing 0.4 mL of electrolyte with 0.05  $\mu$ L of deuterated water (D<sub>2</sub>O), and 0.05  $\mu$ L of dimethyl sulfoxide (DMSO) was added as an internal standard. The presaturation method was employed to eliminate the water peak.

#### Calculations of product and Faradaic efficiency (FE)

$$FE_{gas} = \frac{n \times F \times P \times V_{gas} \times q_{gas}}{i \times R \times T} \times 100\%$$
$$FE_{liquid} = \frac{n \times c \times V_{liquid} \times F}{O} \times 100\%$$

In this equation, n represents the number of electrons transferred to the specific product, which is 2 for formic acid. F is the Faraday constant (96500 C mol<sup>-1</sup>),  $P = 1.01 \times 105$  Pa,  $V_{gas}$  is the volume fraction of the gas product, and  $q_{gas}$  is the gas flow rate. Finally, i(A) is the total current density at each applied potential, R = 8. 314 J mol<sup>-1</sup> K<sup>-1</sup>, T = 298.15 K, c representing the molar concentration of liquid products,  $V_{liquid}$  the volume of cathode electrolyte, and Q (C) the total amount of applied electricity.

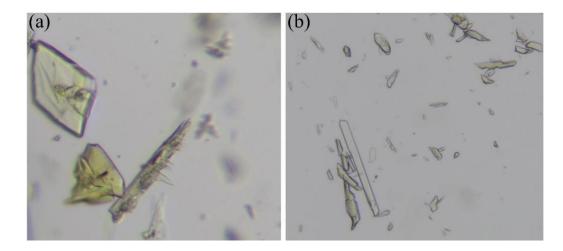


Figure S1. The optical images of Cu-MOF (a) and Co-MOF (b).

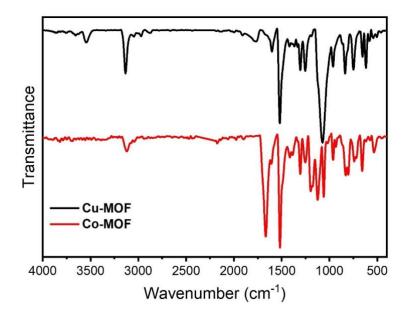


Figure S2. FT-IR spectra of Cu-MOF and Co-MOF.

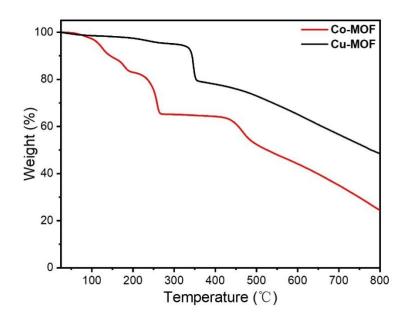


Figure S3. TG curves of Cu-MOF and Co-MOF.

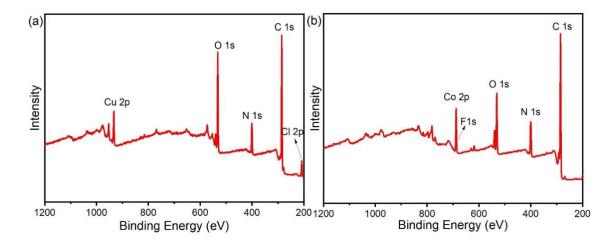
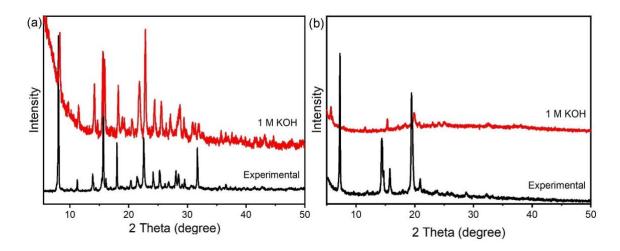


Figure S4. XPS survey spectra of (a) Cu-MOF and Co-MOF.



**Figure S5**. PXRD patterns of **Cu-MOF** (a) and **Co-MOF** (b) after immersing in 1 M KOH for 24 h.

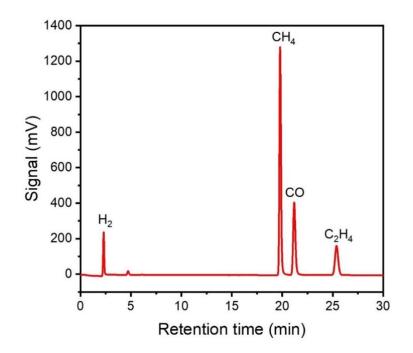


Figure S6. Online GC analysis results of Cu-MOF at an applied potential of -1.28 V (vs. RHE).

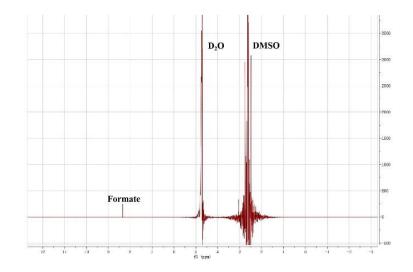


Figure S7. <sup>1</sup>H NMR spectrum of the electrolyte after CO<sub>2</sub>RR.

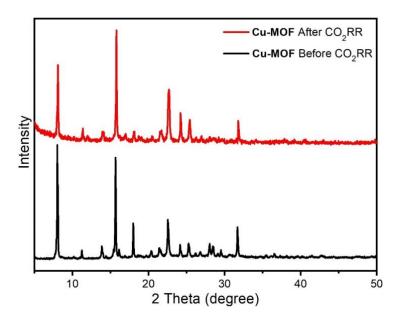


Figure S8. PXRD patterns of Cu-MOF before and after CO<sub>2</sub>RR test.

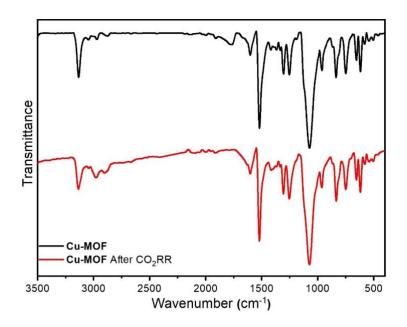


Figure S9. FT-IR spectra of Cu-MOF before and after the CO<sub>2</sub>RR test.

Table S1. Selected bond lengths (Å) and angles (°) for Cu-MOF.

Cu-MOF			
Cu(1)-N(1)	1.872(5)	Cu(1)-N(3)#1	1.877(6)
N3#1-Cu(1)-N(1)	177.2(3)		

Symmetry transformations used to generate equivalent atoms:

#1 -3/2+X, -1/2+Y, -1+Z

Table S2. Selected bond lengths (Å) and angles (°) for Co-MOF.

Co-MOF			
Co(1)-N(1)	2.127(3)	Co(1)-O(3)	2.146(3)
Co(1)-N(4)#1	2.140(3)	Co(1)-N(6)#2	2.156(3)
Co(1)-N(8)#3	2.125(3)	Co(1)-O(1)	2.120(5)
O(1)-Co(1)-N(8)#3	90.8(3)	N(1)-Co(1)-O(3)	94.19(11)
N(1)-Co(1)-N(4)#1	86.95(12)	N(1)-Co(1)-N(6)#2	86.21(12)
O(3)-Co(1)-N(6)#2	84.49(11)	N(4)#1-Co(1)-O(3)	93.44(12)
N(4)#1-Co(1)-N(6)#2	172.69(11)	N(8)#3-Co(1)-N(1)	176.34(13)
N(8)#3-Co(1)-O(3)	87.55(11)	N(8)#3-Co(1)-N(4)#1	96.17(12)
N(8)#3-Co(1)-N(6)#2	90.75(11)	O(1)-Co(1)-N(1)	87.4(3)
O(1)-Co(1)-O(3)	178.0(3)	O(1)-Co(1)-N(4)#1	87.9(3)
O(1)-Co(1)-N(6)#2	94.3(3)		

Symmetry transformations used to generate equivalent atoms:

#1 -1+X, +Y, +Z; #2 +X, 1+Y, 1+Z; #3 -1+X, 1+Y, +Z.

CgI→CgJ	Cg-Cg (Å)	CgI→CgJ	Cg-Cg (Å)
Cg1→Cg1#1	3.526(4)	Cg2→Cg2#2	3.922(4)
C-H→Cg(I)	H…Cg (Å)	$C-H\rightarrow Cg(I)$	H…Cg (Å)
C9-H9→Cg4#3	2.88	C13-H13→Cg1#4	2.89

**Table S3.** Analysis of  $\pi$ ··· $\pi$  and C-H··· $\pi$  interactions in Cu-MOF.

Symmetry codes: #1 -x, y, -z; #2 2-x, y, 2-z; #3 -1/2+x, -1/2+y, z; #4 1/2-x, 1/2+y, 1-z. CgI: the conjugated rings number in **Cu-MOF**; Cg-Cg: distance between ring centroids; H…Cg: distance of hydrogen atoms to ring centroid; H-Perp: perpendicular distance of H to ring plane I; C..Cg: distance of carbon atoms to ring centroid; X-H…Cg: X-H-Cg angle. Cg1: N1 $\rightarrow$ C1 $\rightarrow$ C2 $\rightarrow$ N2 $\rightarrow$ C3; Cg2: N3 $\rightarrow$ C19 $\rightarrow$ C18 $\rightarrow$ N4 $\rightarrow$ C20; Cg3: C4 $\rightarrow$ C5 $\rightarrow$ C6 $\rightarrow$ C7 $\rightarrow$ C8 $\rightarrow$ C9; Cg4: C12 $\rightarrow$ C13 $\rightarrow$ C14 $\rightarrow$ C15 $\rightarrow$ C16 $\rightarrow$ C17.

**Table S4.** Analysis of  $\pi \cdots \pi$  interactions in **Co-MOF**.

CgI→CgJ	Cg-Cg (Å)
Cg1→Cg2#1	4.805(3)

Symmetry codes: #1 3/2-x, -1/2+y, 1/2-z. CgI: the conjugated rings number in **Co-MOF**; Cg-Cg: distance between ring centroids; Cg: distance of carbon atoms to ring centroid; Cg1: C21 $\rightarrow$ C22 $\rightarrow$ C23 $\rightarrow$ C24 $\rightarrow$ C25 $\rightarrow$ C26; Cg2: N3 $\rightarrow$ C17 $\rightarrow$ N4 $\rightarrow$ C18 $\rightarrow$ C19.

**Table S5.** Comparison of the selectivity and partial current density of CH4 production withreported catalysts.

Catalysts	Electrolyte	FE <sub>CH4</sub>	Partial current	Ref.
		(%)	density of CH4	
			(mA cm <sup>-2</sup> )	
Cu@Al-fum MOF	0.1 M KHCO3	6	7	1
Cu–Zn@Al-fum MOF	0.1 M KHCO3	16	5	1
Cu <sub>2</sub> O-QDs@CuHHTPMOF	0.1MKCl/0.1M	73	10.8	2
	KHCO3			
Cu-DBC	0.1 M KHCO3	56	11.4	3
Co-MOF-525	0.1 M LiClO <sub>4</sub> and	14	<10	4
	11M Double-distilled			
	water			
HKUST-1 + CNT	0.5 M KHCO3	4.4	27	5
HKUST-1 on a (GDE)	1 M KOH	15	10	6
Crystalline CuPc	0.5 M KCl	4	0.5	7
Cu NPs with 15 wt%	0.5 M NaHCO <sub>3</sub>	20	4.5	8
Cu <sub>3</sub> (BTC) <sub>2</sub>				
Cu-MOF	1 М КОН	41.5	38.95	This
				work

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